



PATENT
ATTY. DOCKET NO.: P68917US0

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Cheol Hwan PARK, et al.

Group Art Unit: 2812

Serial No.: 10/600,332

Examiner: Stanetta D. Isaac

Filed: June 23, 2003

For: METHOD FOR FORMING DEVICE ISOLATION FILM OF
SEMICONDUCTOR DEVICE

AMENDMENT UNDER RULE 1.111

Commissioner for Patents
Mail Stop Amendment
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Office Action mailed July 28, 2004 (Paper No. 0704), kindly
amend the above-identified patent application as set forth herein.